



IPW

Docket No.: 61282-034

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of : Customer Number: 20277  
Mitsumi ITO, et al. : Confirmation Number: 7464  
Serial No.: 10/634,989 : Group Art Unit: 2812  
Filed: August 06, 2003 : Examiner: not yet assigned  
  
For: SEMICONDUCTOR DEVICE, METHOD OF GENERATING PATTERN FOR  
SEMICONDUCTOR DEVICE, METHOD OF MANUFACTURING SEMICONDUCTOR  
DEVICE AND DEVICE FOR GENERATING PATTERN USED FOR  
SEMICONDUCTOR DEVICE

**INFORMATION DISCLOSURE STATEMENT**

Mail Stop IDS  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

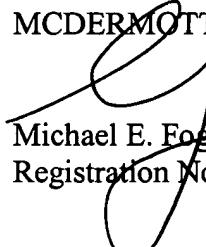
This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

The relevance of the Japanese language reference, JP 2001-356279, is discussed in the present specification.

Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

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**Date: June 24, 2004**



SHEET 1 OF 1

**\*EXAMINER:** Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.